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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : **Confirmation No. 6163**  
Toshikazu TACHIKAWA et al. : Docket No. 2002\_0069  
Serial No. 10/053,622 : Group Art Unit 1752  
Filed January 24, 2002 : Examiner Rosemary E. Ashton

NEGATIVE-WORKING PHOTORESIST  
COMPOSITION

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TC 1700

**RESPONSE**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In response to the Official Action dated August 6, 2003, please amend the present application as follows:

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